Electronic Supplementary Information

Hierarchical Heterostructures of MnO₂ Nanosheets or Nanorods Grown on Au-Coated Co₃O₄ Porous Nanowalls for High Performance Pseudocapacitance

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Fig. S1 Low-magnification SEM image showing as-grown Co_3O_4 porous nanowalls on macroporous Ni foam.



Fig. S2 XRD patterns demonstrate a transformation of $Co(OH)_2$ to Co_3O_4 after thermal annealing at 250 °C. The up pattern matches well with that of hexagonal α -Co(OH)₂ phase by referring to JCPDS card (no.: 74-1057),¹ while the bottom pattern can be indexed to that of cubic Co_3O_4 phase by referring to JCPDS card (no.: 43-1003).² Here, a broad weak peak (centered at $2\theta = \sim 25^\circ$) of both patterns is due to glass substrate during the XRD measurements.



Fig. S3 High-manification SEM image of dense and fine MnO_2 nanosheets grown on the Au-coated Co_3O_4 porous nanowalls, appearing like a kind of coral (an upper-left inset).



Fig. S4 HRTEM image shows that as-grown MnO_2 nanosheet is as thin as ~ 2-3 nm.



Fig. S5 High-manification SEM image of as-grown MnO_2 nanorods on the Au-coated Co_3O_4 nanowall arrays.



Fig. S6 XPS spectrum acquired from the $Co_3O_4@Au@MnO_2(NRs)$ hierarchical heterostructures.



Fig. S7 CV curves recorded from the Ni foam and as-grown Co_3O_4 porous nanowalls, respectively, at a scan rate of 50 mV s⁻¹.



Fig. S8 Galvanostatic charge-discharge curves of the $Co_3O_4@Au@MnO_2(NSs)$ hierarchical heterostructures at different current densities.

Specific capacitance calculation

The specific capacitance of the electrode was calculated from the C-V curves

according to the following equation:³

$$C = \frac{Q}{\Delta V * m}$$

where C (F g⁻¹) is the specific capacitance, m (g) is the mass of the active materials in the electrodes, Q (C) is an average charge during the charging and discharging processes, and ΔV (V) is the potential window.

The discharge specific capacitance is calculated from the discharge curves using the following formula: ³

$$C = \frac{I * \Delta t}{m * \Delta V}$$

where I (A), Δt (s), m (g), and ΔV (V) are the discharge current, discharge time consumed in the potential range of ΔV , mass of the active materials, and the potential windows, respectively.

The power density and energy density are calculated from the following equations, respectively: ³

$$E = \frac{1}{2}C * \Delta V^{2}$$
$$P = \frac{E}{t}$$

where P (kW kg⁻¹), C (F g⁻¹), ΔV (V), t (s), and E (W h kg⁻¹) are the power density, specific capacitance, potential window of discharge, discharge time, and energy density, respectively.

Reference

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